# Supplementary information

# Fabrication of antimony doped tin oxide-graphene nanocomposite for high effective capacitive deionization of saline water

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#### 1. Materials and Characterization

Graphite powder (KS-10) for graphite oxide (GO) preparation, H<sub>2</sub>SO<sub>4</sub> (98%), H<sub>3</sub>PO<sub>4</sub> (85%), KMnO<sub>4</sub> (A. R.), H<sub>2</sub>O<sub>2</sub> (30%), HCl (37%), SnCl<sub>2</sub>·2H<sub>2</sub>O (98%), SbCl<sub>3</sub> (99%) and NH<sub>3</sub>·H<sub>2</sub>O (25%) were used without any further purification. All the above reagents were purchased from Sinopharm Chemical Reagent Company Limited.

The surface morphology of the composite was studied by a JEOL JSM-5900 scanning electron microscope (JEOL Ltd., Japan) and field-emission scanning electron microscope (FESEM Hitachi S-7400, Japan). High-resolution transmission electron microscopy (HRTEM) was performed by JEOL-2100F. The phase and crystallinity were characterized using a Rigaku X-ray diffractometer (Rigaku Co., Japan) with Cu K $\alpha$  ( $\lambda$ =1. 54056 Å) radiation over a range of 2 $\theta$  angles from 5° to 80°. The electrochemical performances of the electrodes were determined using a Versa Stat 4 potentiostat device. The N<sub>2</sub> sorption isotherms and pore size distribution were tested using a 3H-2000PM2 micropore structure analyzer (Beishide Co., Beijing). The chemistry state of elements was evaluated by X-ray photoelectron spectroscopy instrument (XPS, Thermo ESCALAB 250xi spectrophotometer with Al–K $\alpha$  radiation). Thermogravimetric analysis (TGA) was performed under air flow from 30°C to 800°C using a NETZSCH STA 449F3 TGA apparatus. Electrochemical experiments were performed with a CHI660E Electrochemical Workstation.

#### 2. The preparation of graphene oxide

Graphene oxide (GO) was synthesized using conventional Hummer's method with slight modification<sup>1</sup>. 2 g of graphite powder was treated by 180 mL of H<sub>2</sub>SO<sub>4</sub> and 20 mL of H<sub>3</sub>PO<sub>4</sub> in a 500 mL round-bottomed flask. With constant stirring, 12 g of KMnO<sub>4</sub> was slowly added in the ice bath to keep the reaction temperature lower than 20°C. Then the mixture was heated to 50°C and the reaction was kept for 10 h. The reactant was cooled down to room temperature and H<sub>2</sub>O<sub>2</sub> (30%) was injected. Finally, after washing with HCl (10%) and DI water, the mixture was centrifuged for several times and then dried at 60°C for 12 h.

### 3. EDX of the fabricated SnO<sub>2</sub>-RGO (20 wt.%) nanocomposite



Fig. S1. EDX of the fabricated SnO<sub>2</sub>-RGO (20 wt.%) nanocomposite

### 4. C 1s region in the XPS spectrum of pure RGO



Fig. S2. C 1s region in the XPS spectrum of pure RGO

5. CV curves of pristine RGO and ATO-RGO composites with different mass ratios between ATO and graphene at different scan rates



**Fig. S3.** CV measurements for (A) RGO, (B) ATO-RGO (10 wt.%), (C) ATO-RGO (20 wt.%), (D) ATO-RGO (30 wt.%) and (E) ATO-RGO (40 wt.%) modified electrodes in 1 M NaCl solution at the scan rates from 5 to 100 mV s<sup>-1</sup>, respectively.

#### 6. The specific capacitance of SnO<sub>2</sub>-RGO (20 wt.%).



**Fig. S4.** (A) CV measurement in 1 M NaCl solution at the scan rates of 5 mV s<sup>-1</sup> and (B) chargedischarge test at a current density of 1 A g<sup>-1</sup> for SnO<sub>2</sub>-RGO (20 wt.%) electrode.

7. CDI performance at different applied voltage in the testing solution.



Fig. S5. CDI performance at different applied voltage in the testing solution.

## Reference

1 Y. X. Xu, K. X. Sheng, C. Li and G. Q. Shi, *Acs Nano*, 2010, 4, 4324-4330.